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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Wu et al.

Serial No.: 10/672,778

Filed: September 26, 2003

For: Atomic Layer Deposition (ALD) Method with  
Enhanced Deposition Rate

Group Art Unit: 2891

Examiner: Smith, Bradley

Confirmation No.: 9717

TKHR Docket: 252016-3000


Top-Team: 0503-8501DUS

## CERTIFICATE OF FACSIMILE TRANSMISSION UNDER 37 CFR §1.8

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October 18, 2005

Date

  
Hui Chin BarnhillRESPONSE TO RESTRICTION/ELECTION REQUIREMENTS

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed September 22, 2005 has been carefully considered. In further response thereto, please enter the following amendments and consider the following remarks.

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